

# Fabrication of $X_3\text{Sn}$ ( $X=\text{Fe}, \text{Mn}$ ) epitaxial films and the magnetic and electronic properties

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## Introduction

Transition metal - tin alloys have been paid attention as materials for spintronics devices in recent years. For example,  $\text{D0}_{19}$   $\text{Mn}_3\text{Sn}$  which is frustrated antiferromagnetic material was reported to exhibit large anomalous Hall effect because of its Berry curvature of Weyl points<sup>1</sup>. On the other hand,  $\text{Fe}_3\text{Sn}_2$  and  $\text{Fe}_3\text{Sn}$  were expected to show intrinsic anomalous Hall effect which is useful for Hall sensor<sup>2,3</sup>. For the applications, high-quality epitaxial growth of these materials is indispensable, however it has not been achieved yet. In this work, we fabricated  $\text{D0}_{19}$  type  $\text{Fe}_3\text{Sn}$  and  $\text{Mn}_3\text{Sn}$  epitaxial films and measured their physical properties. In addition, we compared magneto-transport properties of  $\text{D0}_{19}$  and B2  $\text{Fe}_3\text{Sn}$  which we developed recently<sup>4</sup>.

## Experiment

The samples were prepared by Molecular Beam Epitaxy (MBE) method. Stacking structures were as follows:  $\text{Al}_2\text{O}_3$  (0001) substrate / Pt 6nm /  $\text{Fe}_3\text{Sn}$  or  $\text{Mn}_3\text{Sn}$  30 nm /  $\text{Al}_2\text{O}_3$  5nm. Temperature of substrates during the depositions were  $400^\circ\text{C}$  and  $300^\circ\text{C}$  for  $\text{Fe}_3\text{Sn}$  and  $\text{Mn}_3\text{Sn}$ , respectively.

## Results

Figure 1 shows RHEED pattern for the  $\text{Mn}_3\text{Sn}$  film, which is clear streak pattern indicating epitaxial growth. We also confirmed the epitaxial growth of the films by XRD. With regard to Hall effect, B2 and  $\text{D0}_{19}$   $\text{Fe}_3\text{Sn}$  exhibited clear Hall effect as shown in Fig.2. The Hall resistivity of B2 was 7 times larger than that of  $\text{D0}_{19}$   $\text{Fe}_3\text{Sn}$ . On the contrary,  $\text{Mn}_3\text{Sn}$  films did not showed Hall resistivity. These small Hall effect for  $\text{D0}_{19}$  alloy could be attributed to the anisotropic crystal structure<sup>1</sup>.

## References

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Fig.1 RHEED pattern of  $\text{Mn}_3\text{Sn}$ .

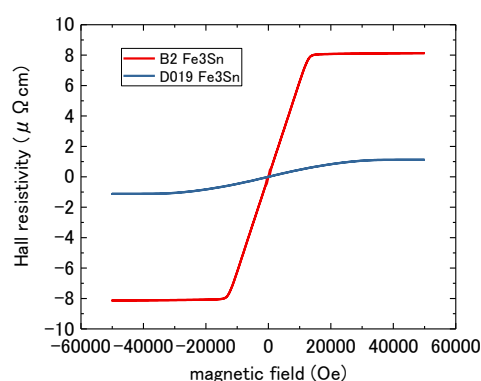


Fig.2 Hall resistivity of B2 and  $\text{D0}_{19}$   $\text{Fe}_3\text{Sn}$ .